L Number	Hits	Search Text	DB	Time stamp
1	298479	mask or photomask or reticle	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:05
2	768192	shift or shifter or shifted or shifting	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:05
3	7733	(seed or seeding) adj4 layer	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:08
4	184427	rough or roughness	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:26
5	2962	((seed or seeding) adj4 layer) and (mask or photomask or reticle)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:09
6	53706	(shift or shifter or shifted or shifting) and (mask or photomask or reticle)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:09
7	388	(rough or roughness) and (((seed or seeding) adj4 layer) and (mask or photomask or reticle))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:11
8	49374	1.clm.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:11
9	81	((rough or roughness) and (((seed or seeding) adj4 layer) and (mask or photomask or reticle))) and 1.clm.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:11
10	27675	(chromium or cr) and (mask or photomask or reticle)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:12
11	24	(((rough or roughness) and (((seed or seeding) adj4 layer) and (mask or photomask or reticle))) and 1.clm.) and ((chromium or cr) and (mask or photomask or reticle))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:14
12	57	(((rough or roughness) and (((seed or seeding) adj4 layer) and (mask or photomask or reticle))) and 1.clm.) not (((((rough or roughness) and (((seed or seeding) adj4 layer) and (mask or photomask or reticle))) and 1.clm.) and ((chromium or cr) and (mask or photomask or reticle)))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:14
13	6368	1.clm. and ((chromium or cr) and (mask or photomask or reticle))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:15
14	2171	((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:15
15	269	(((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))) and (rough or roughness)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:25
16	3375	rms and (mask or photomask or reticle)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:26
17	269	((chromium or cr) and (mask or photomask or reticle)) and (((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))) and (rough or roughness))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:26

18	269	1.clm. and (((chromium or cr) and (mask or photomask or reticle)) and ((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))) and (rough or roughness)))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:26
19	13775	4.clm.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:26
20	24	((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))) and (rough or roughness)) and (rms and (mask or photomask or reticle))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:26
21	24	((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))) and (rough or roughness)) and 4.clm.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:27
22	24	(1.clm. and (((chromium or cr) and (mask or photomask or reticle)) and ((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (1.clm. and ((chromium or cr) and (mask or photomask or reticle)))) and (rough or roughness)))) and 4.clm.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:42
23	91955	nuclei or nucleate	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:45
24	2281	428/432.ccls.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:46
25	118	((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.	USPAT; US-PGPUB; EPO; JPO	2003/08/14 14:46
26	20	(rough or roughness) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 15:22
27	35	((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)	USPAT; US-PGPUB; EPO; JPO	2003/08/14 15:22
28	30	(((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)) not ((rough or roughness) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 15:29
29	0	(rough or roughness) and ((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)) not ((rough or roughness) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 15:30
30	1	((seed or seeding) adj4 layer) and ((((shift or shifter or shifted or shifting) and (mask or photomask or reticle)) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)) not ((rough or roughness) and (((chromium or cr) and (mask or photomask or reticle)) and 428/432.ccls.)))	USPAT; US-PGPUB; EPO; JPO	2003/08/14 15:30